Attorney's Docket No.: 14564-021US1

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Greg Charache et al.

Art Unit : Unknown Examiner: Unknown

Serial No.:

Filed

: July 19, 2006

Title

: HIGH-POWER SEMICONDUCTOR LASER

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

## INFORMATION DISCLOSURE STATEMENT

Applicants request consideration of the references listed on the attached PTO-1449 form. Under 37 C.F.R. § 1.98 (a)(2)(ii), only copies of foreign patent documents and/or non-patent literature are enclosed. Copies of any listed U.S. patents or U.S. patent application publications can be provided upon request.

This statement is being filed with the application. Please apply any charges or credits to Deposit Account No. 06-1050.

Respectfully submitted,

July 19, 2006

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Substitute Form PTO-1449 U.S. Department of Commerce (Modified) Patent and Trademark Office				
Information Disclosure Statement by Applicant (Use several sheets if necessary)		Applicant Greg Charache et al.		
		Filing Date July 19, 2006	Group Art Unit	

U.S. Patent Documents							
Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA	5,691,989	11/25/97	Rakuljic et al.			
	AB						
	AC						
	AD						
	AE						
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	AG						
	AH						
	AI						
	AJ						
	AK						:

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner	Desig.	Document	Publication	Country or			Trans	lation
Initial	ID D	Number	Date	Patent Office	Class	Subclass	Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

Other Documents (include Author, Title, Date, and Place of Publication)				
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EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with			

next communication to applicant.